Curriculum Vitae

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Education

Kanazawa Institute of Technology, College of Engineering, Department of Electrical and Electronic Engineering, B.S., May 1983

Employment Experience

Employee, Fujikin Incorporated, March 1983 to January 1988.

Employee, Mechatro-Tech Team, Osaka High-Tech Research and Development Center, Fujikin Incorporated, involved in the development, design and performance evaluation of electrical control devices for flow control apparatuses, including mass flow controllers, mass flow meters, and electric driven valves, January 1988 to October 2006.

Manager, Mechatro-Tech Team, Osaka High-Tech Research and Development Center, Fujikin Incorporated, Osaka High-Tech Research and Development Center, managing the Mechatro-Tech Team as section chief, involved in the development, design and performance evaluation of electrical control devices for flow control apparatuses, including mass flow controllers, mass flow meters, and electric driven valves, as well as involved in the research and development of pressure type flow control devices for fluid passages, and methods for internal pressure control of a chamber, October 2006 to present.

Publications/Patents

- U.S. Patent No. 6,964,279, issued November 15, 2005, Pressure-type Flow Rate Control Apparatus.
- U.S. Patent No. 7,594,517, issued September 29, 2009, Gas Supply Facility of a Chamber and a Method for an Internal Pressure Control of the Chamber for which the Facility is Employed.